

プラズマ処理装置1

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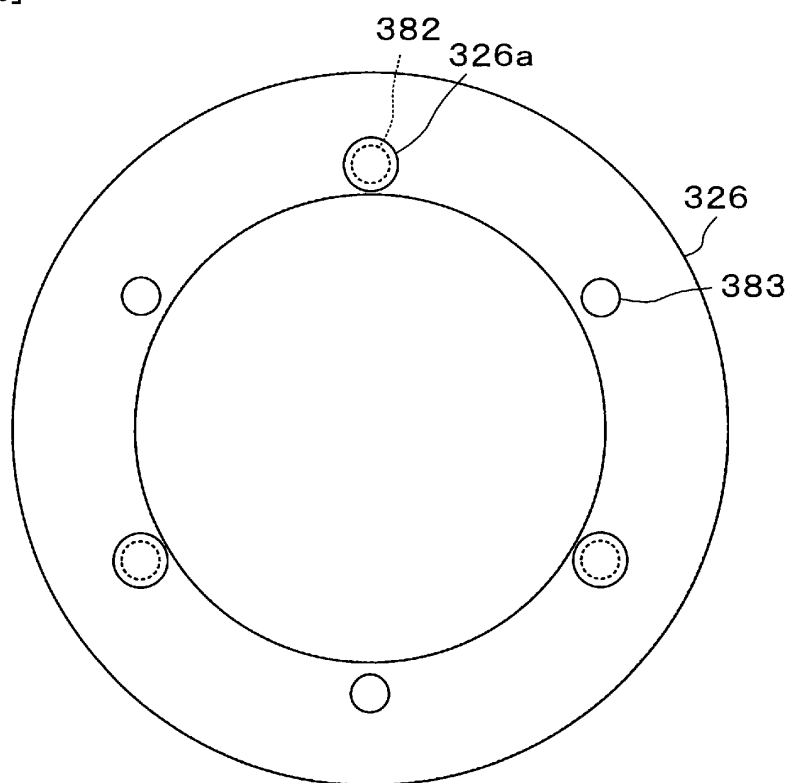
制御部2

2a		
2a1	2a2	2a3

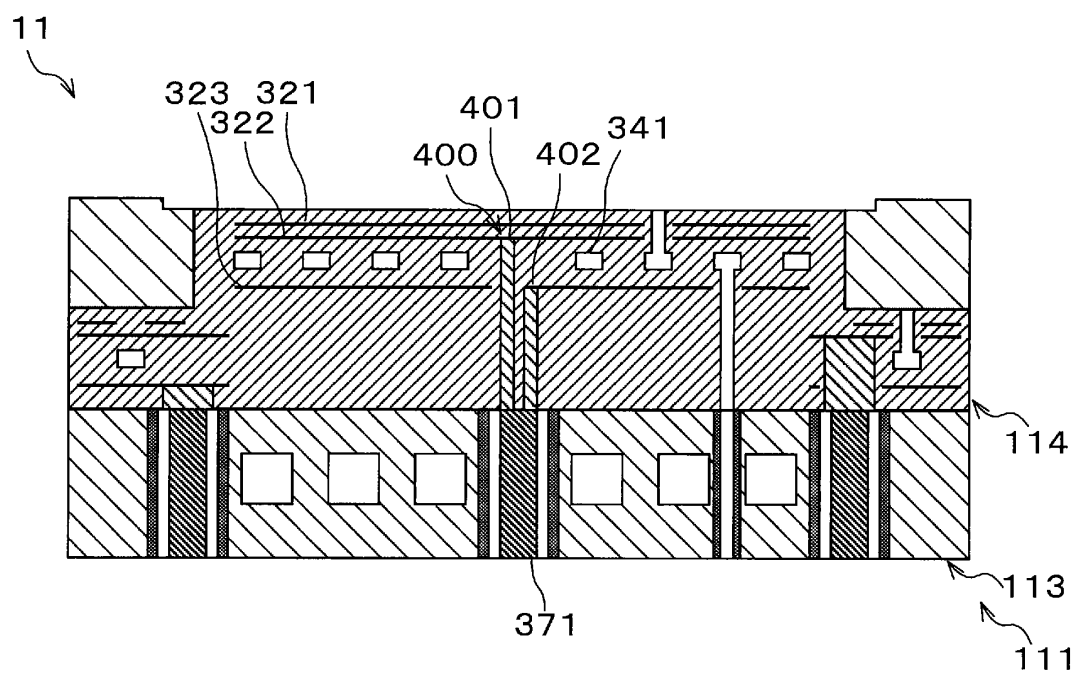
[illegible]

FIG. 3 is a schematic diagram of a circular structure. It consists of a large outer circle and a smaller inner circle, both centered at the same point. Three small circles are positioned within the annular region between the two larger circles. One small circle is located at the top center, and the other two are positioned symmetrically on the left and right sides. A label '382' with a leader line points to the top small circle. A label '325' with a leader line points to the outer boundary of the large circle.

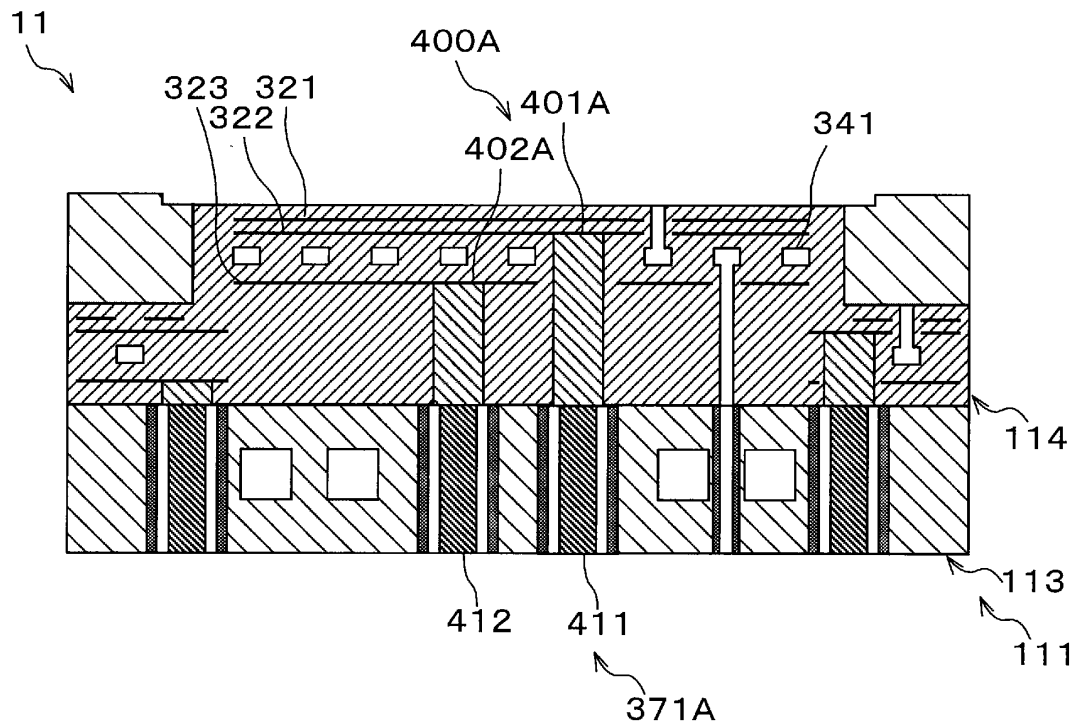
[図5]



[図6]



[図7]



[図8]

